Solution-Processed High-Haze ZnO Pyramidal Textures Directly Grown on a TCO substrate and Light-Trapping Effect in Cu_2O Solar Cells

Tsutomu Shinagawa,[a] Kosuke Shibata,[b] Osamu Shimomura,[b] Masaya Chigane,[a] Ryôki Nomura[b] and Masanobu Izaki[c]*

[a]Electronic Materials Research Division, Osaka Municipal Technical Research Institute, Osaka 536-8553, Japan.

[b]Department of Applied Chemistry, Osaka Institute of Technology, Osaka 535-8585, Japan.

[c]Department of Mechanical Engineering, Toyohashi University of Technology, Toyohashi, Aichi 441-8580, Japan.

**E-mail: tshina@omtri.or.jp*

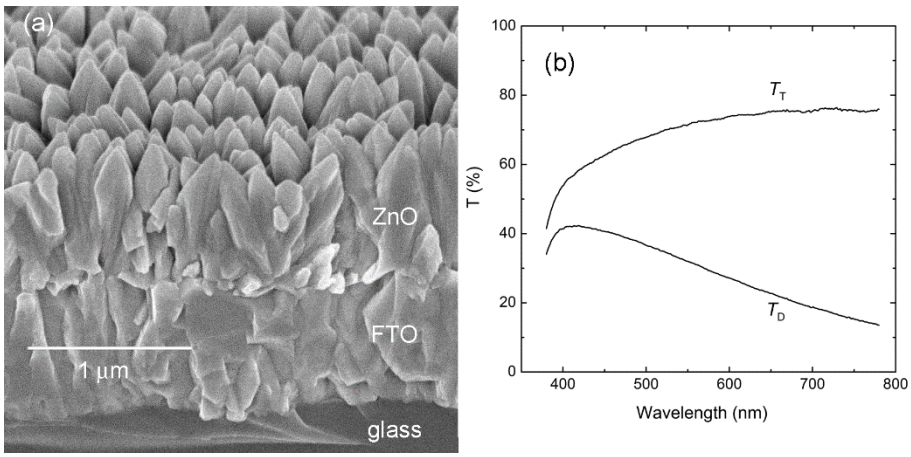

Figure S1. (a) FESEM image and (b) T_T and T_D spectra of a ZnO film electrodeposited from a 15 mM $Zn(NO_3)_2 \cdot 6H_2O$−15 mM NaCl aqueous solution at a current density of 2.0 mA cm^{-2} for 450 s.

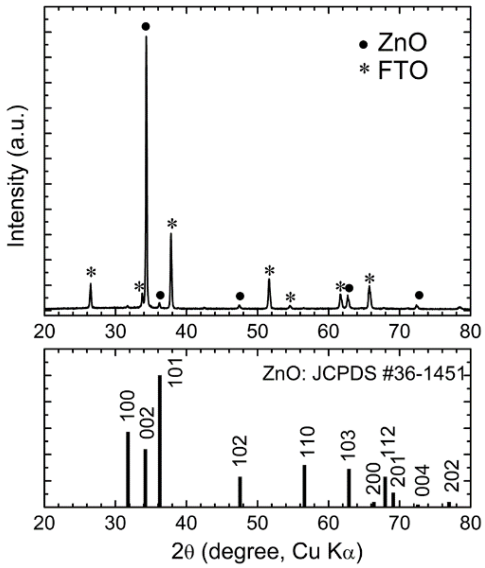

Figure S2. XRD pattern of a pyramidal-textured ZnO film. JCPDS data (no. 36-1451) for ZnO is also presented.